We Are Keep Moving Toward the Future

Samsung Electronics, the world's leading electronics company's driving force is R&D capability.
Samsung R&D Institute Japan and our proud engineers keep innovating and pioneering over the technical horizon.
Our highly valued R&D powers will remain next and post-next generation.

Samsung R&D Institute Japan

http://www.samsung-srj.co.jp

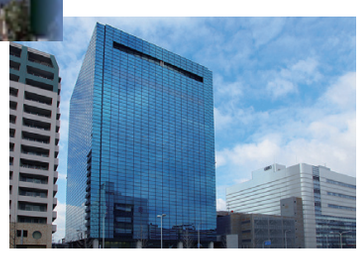
SAMSUNG

Company Overview

Samsung Electronics' R&D Foundation in Japan

Being the world's top class research center as our primary vision, we are actively developing innovative components and cultivating core technologies in electronics industry.
Yokohama office's site area is 7,200 square meter and the total floor area is 19,000 square meter, 6 floors above ground and 2 below. Osaka office's total floor area is 22,000 square meter,
14 floors above ground and 1 below.
We will keep enhancing Samsung Electronics' competitiveness in worldwide and supporting local society through our highest standard R&D expertise.

Yokohama



Osaka

Establishment

August 1992

Business Area

Development of electrical components, mobile equipments, and computer related devices

History

1992. 8	Started as a research corporation “AITECH“
1996. 8. 9	Relocation to a new office (Address: Hamamachi Center bldg. 2-31-1, Nihonbashi Hamamachi, Tokyo)
1997. 6.30	Relocation to Yokohama (Address: 2-7 Sugasawa-cho, Tsurumi-ku, Yokohama)
1998. 1. 1	Renamed to "Samsung Yokohama Research Institute Co., Ltd."
2002. 5	Osaka office was established
2012. 4	Osaka office was granted as an official "research institute "
2013. 7. 1	Renamed to "Samsung R&D Institute Japan Co. Ltd.

R&D Themes

Expertise in Local Competitiveness

We never settle for mediocrity.

Our master plan to deliver the indispensable result is "Selective Concentration".

Our carefully chosen 5 research themes are listed below.

Energy and Material

High Power and High safety Lithium-ion Rechargable Battery,

Ceramics, and The Next Generation Display Materials

Life Appliances

System A/C, Refrigerators, Washing Machines, and Its Core Motors, Inverters.

Also Any Related-Foundational Air/Water Reforming Technologies

Image Processing

Circuit Design, ASIC, Compression, Image Enhancement, Rapid Transfer.

OLED, The Next Generation Display Technology,

Low-Cost Processing, Elaborated Driving Technology.

Optics/Mechatronics

Various Devices Based on Mechatronics Technology.

Aspheric Lens Engineering For Optical Proudcts. Optical Engine For Projectors.

Semiconductor

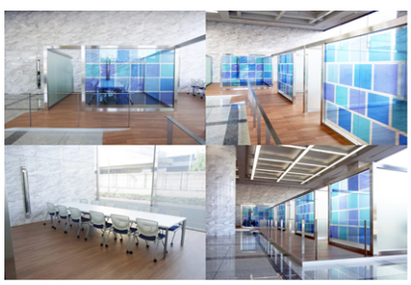
Memory and Device Circuit Engineering with Top-Notch Miniaturization Technology.

Facility Yokohama

Sophisticated R&D Facility

Spacious and refined atmosphere to motivate and cultivate employees' creativity and inspiration.

Lobby

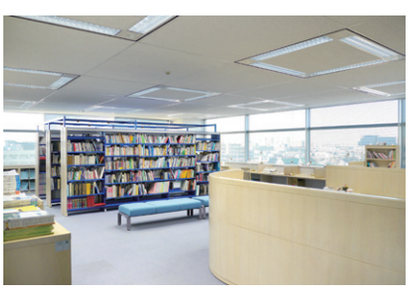


1F Meeting Space

Café & Refreshment Space

Video Conference Room

Auditorium

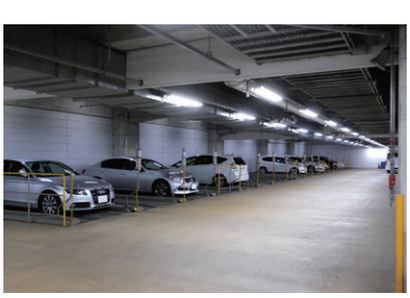


Reference Room

Office Cafeteria

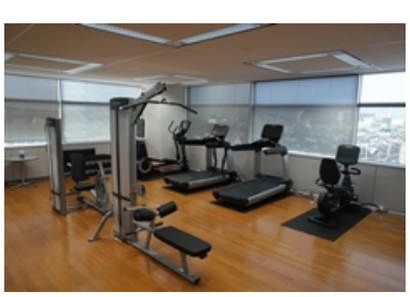
Clean Room

Information Systems Office



Underground Parking Lot

Laboratory



Fitness Room

Facility Osaka

15-Story Facility of Innovation

Since 2002, We are expanding our facilities and supporting the Future innovation.

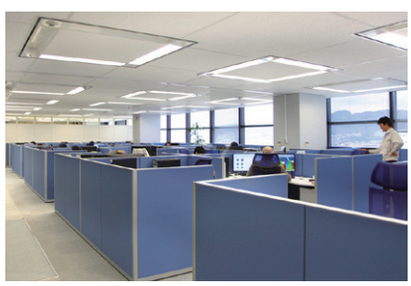
Reception

Entrance

Café

Video Conference Room

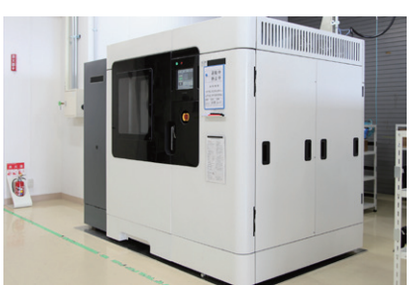
Auditorium


Office

Office Cafeteria

Test Chamber

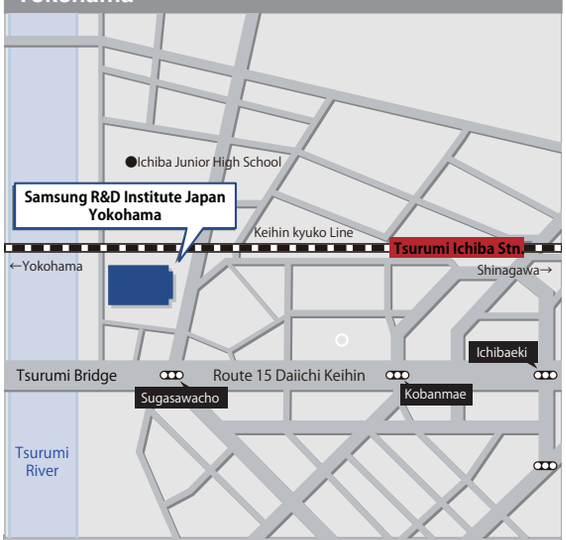
Server Room


3D Printer

Ceramic Granulometer

Parking Lot

Yokohama



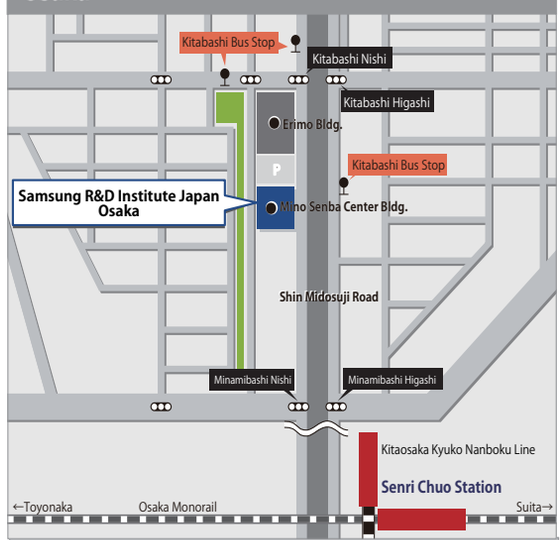
Samsung R&D Institute Japan Yokohama Office

2-7, Sugasawacho, Tsurumiku, Yokohama, Kanagawa
TEL +81-45-510-3331

Access

5 minutes on foot from Tsurumi Ichiba Station
◎Haneda Airport ⇒ Keihin Kyuko Line approximately 30 minutes (Keihin Kamata Station Transit)
⇒ Keihin Kyuko Line "Tsurumi Ichiba Station"

Osaka



Samsung R&D Institute Japan Osaka Office

Mino Senba Center bldg. 2-1-11 Senbanishi, mino, Osaka
TEL +81-72-730-2172

Access

Hankyu Bus : Get on line "Senri Chuo Station." No. 7 (81, 82, 83, 85 lines),
or No.11 (19, 20, 60, 63 lines) and get off at "New Hochiba Kitabashi"
※ 5 minutes from taxi "Senri Chuo station"

◎ Osaka Airport ⇒ Osaka Monorail (12 Minutes) ⇒ Senri Chuo Station
◎ Kansai Airport ⇒ JR Limited Express (34 Minutes) ⇒ Tennoji Station
⇒Metro Midosuji Line (34 Minutes) ⇒ Senri Chuo Station